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Gunther et al.

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(54) **TARGET PROFILE FOR A PHYSICAL VAPOR DEPOSITION CHAMBER TARGET**

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(**) Term: **15 Years**

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Related U.S. Application Data

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(51) **LOC (13) Cl.** **15-09**

(52) **U.S. Cl.**
USPC **D15/138**; D13/182

(58) **Field of Classification Search**
USPC D23/249, 259, 262, 269; D15/138, 139, D15/143, 144, 144.1, 144.2, 150, 199;
(Continued)

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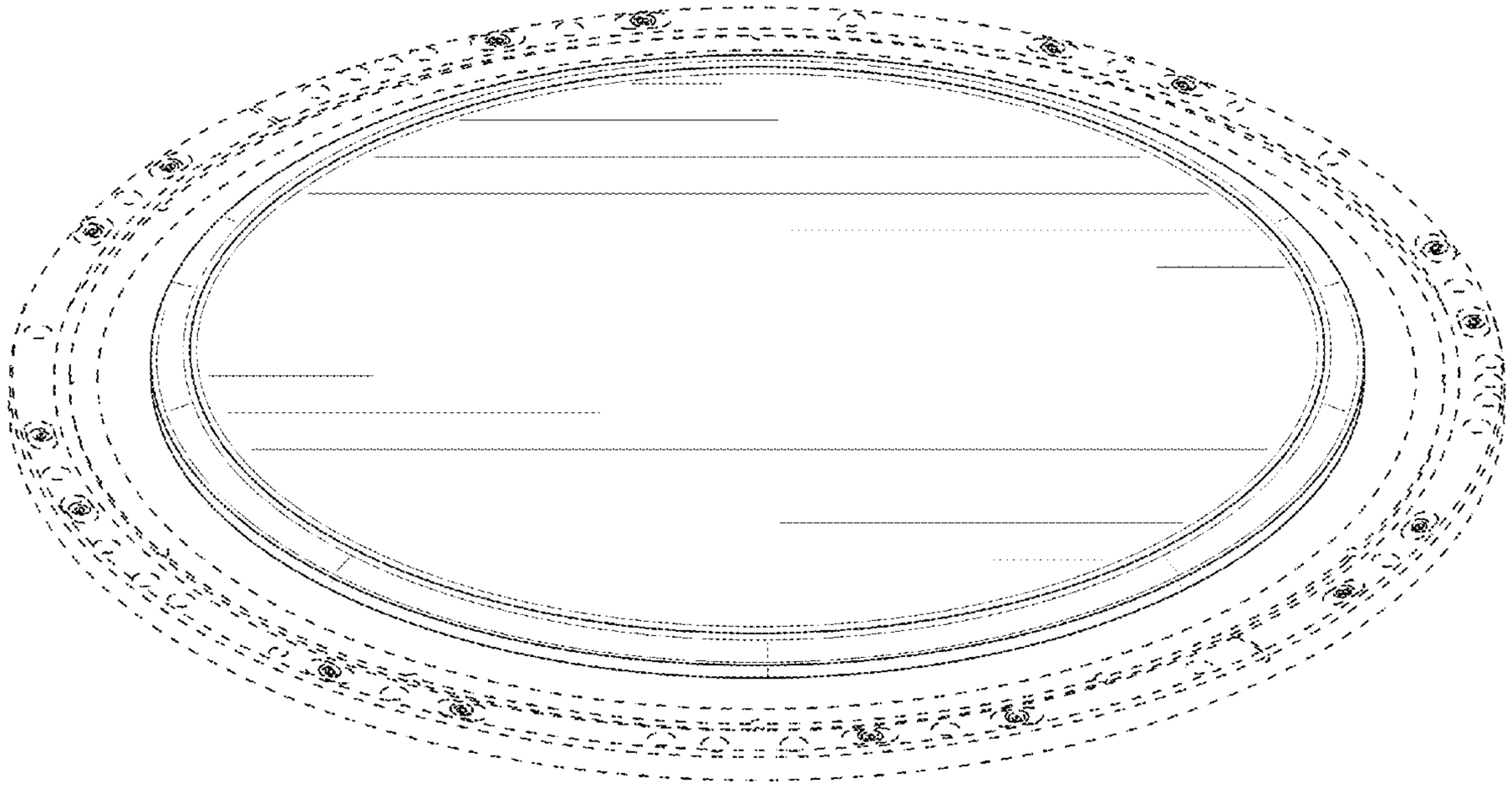
(57) **CLAIM**

We claim the ornamental design for a target profile for a physical vapor deposition chamber target, as shown and described.

DESCRIPTION

FIG. **1** is a top isometric view of a sputter target for a physical vapor deposition chamber, according to our novel design.
FIG. **2** is a top plan view thereof.
FIG. **3** is a bottom plan view thereof.
FIG. **4** is a right side elevation view thereof.
FIG. **5** is a left side elevation view thereof.
FIG. **6** is a front elevation thereof.
FIG. **7** is a back elevation view thereof; and,
FIG. **8** is an enlarged partial right side elevation view showing portions of the design in greater detail.
The broken lines in the drawings represent unclaimed environment and form no part of the claimed design.
The long dash short dash broken lines in FIGS. **4** and **8** represent the region of enlargement taken from FIG. **4** as shown in FIG. **8** and form no part of the claimed design.

1 Claim, 6 Drawing Sheets



(58) **Field of Classification Search**
USPC D13/118, 122, 133, 162, 182, 184, 199; D22/113, 119
CPC H01J 37/3414; H01J 37/3423; H01L 21/02631; H01L 2221/68363; H01L 2224/75186–75189; H01L 21/67742; H01L 21/0226; H01L 21/02263; H01L 21/02266; H01L 21/02269; H01L 21/02271; F16J 7/00; E04D 13/14; C23C 14/3407; C23C 14/35
See application file for complete search history.

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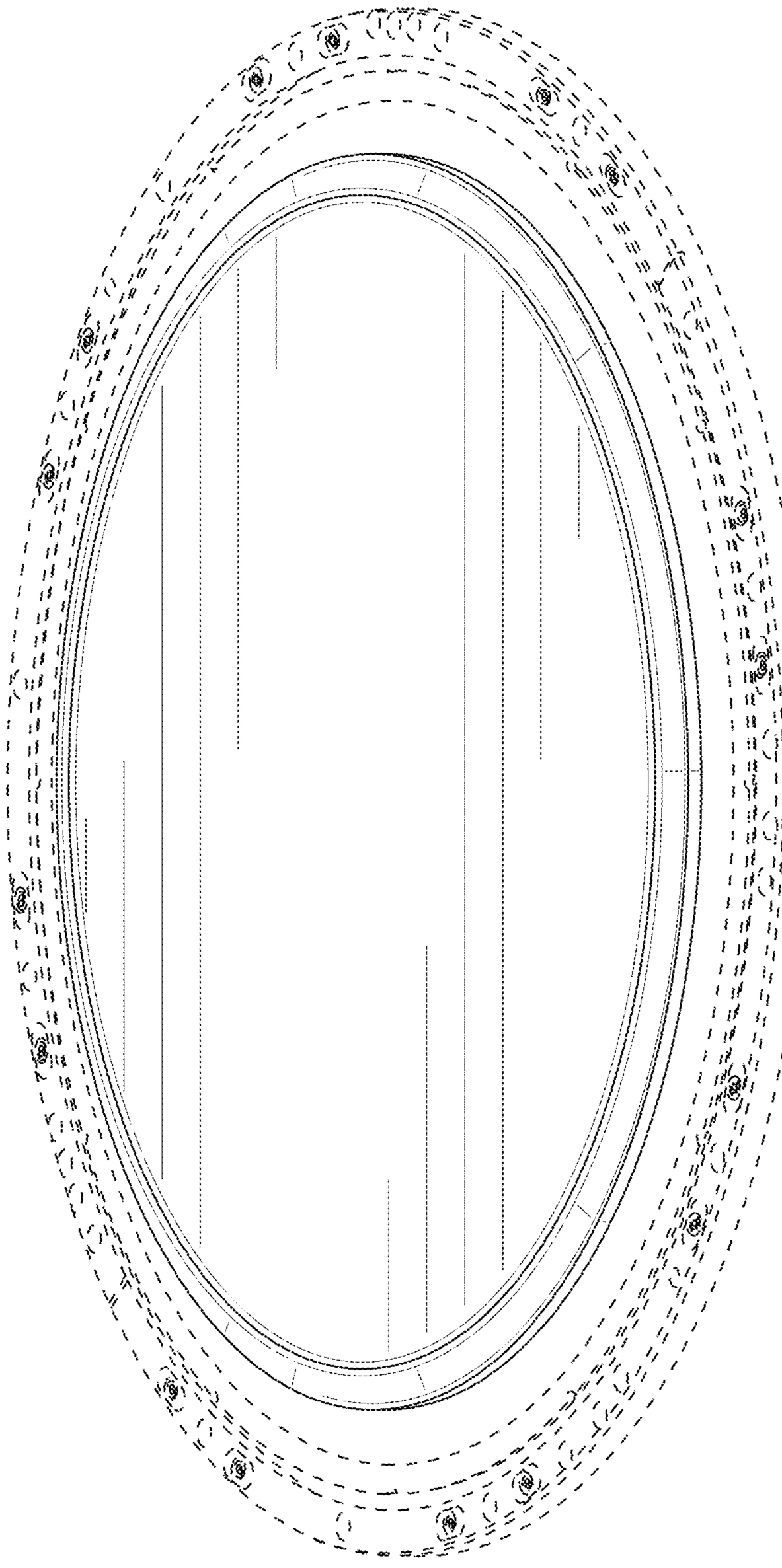

FIG. 1

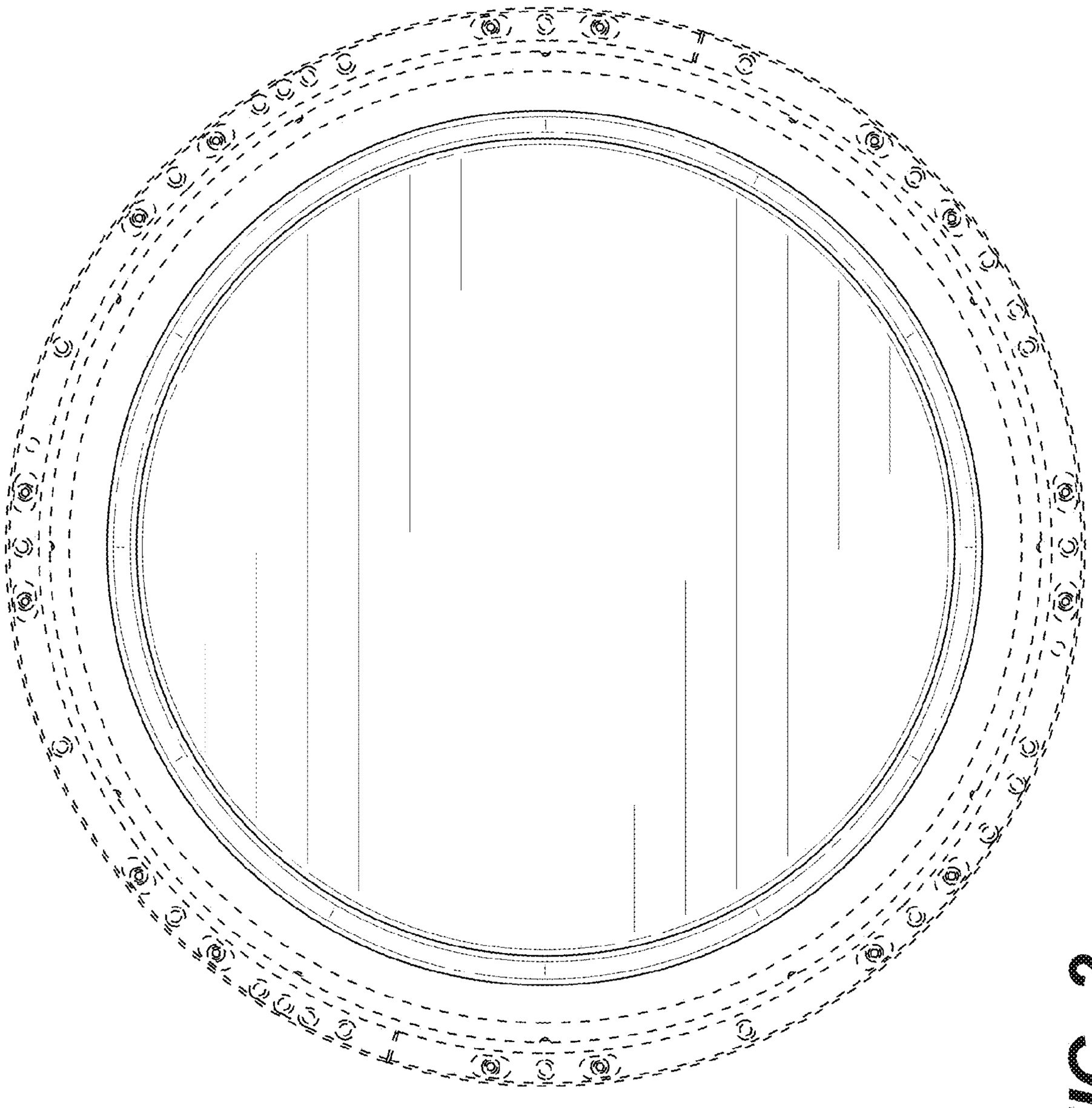

FIG. 2

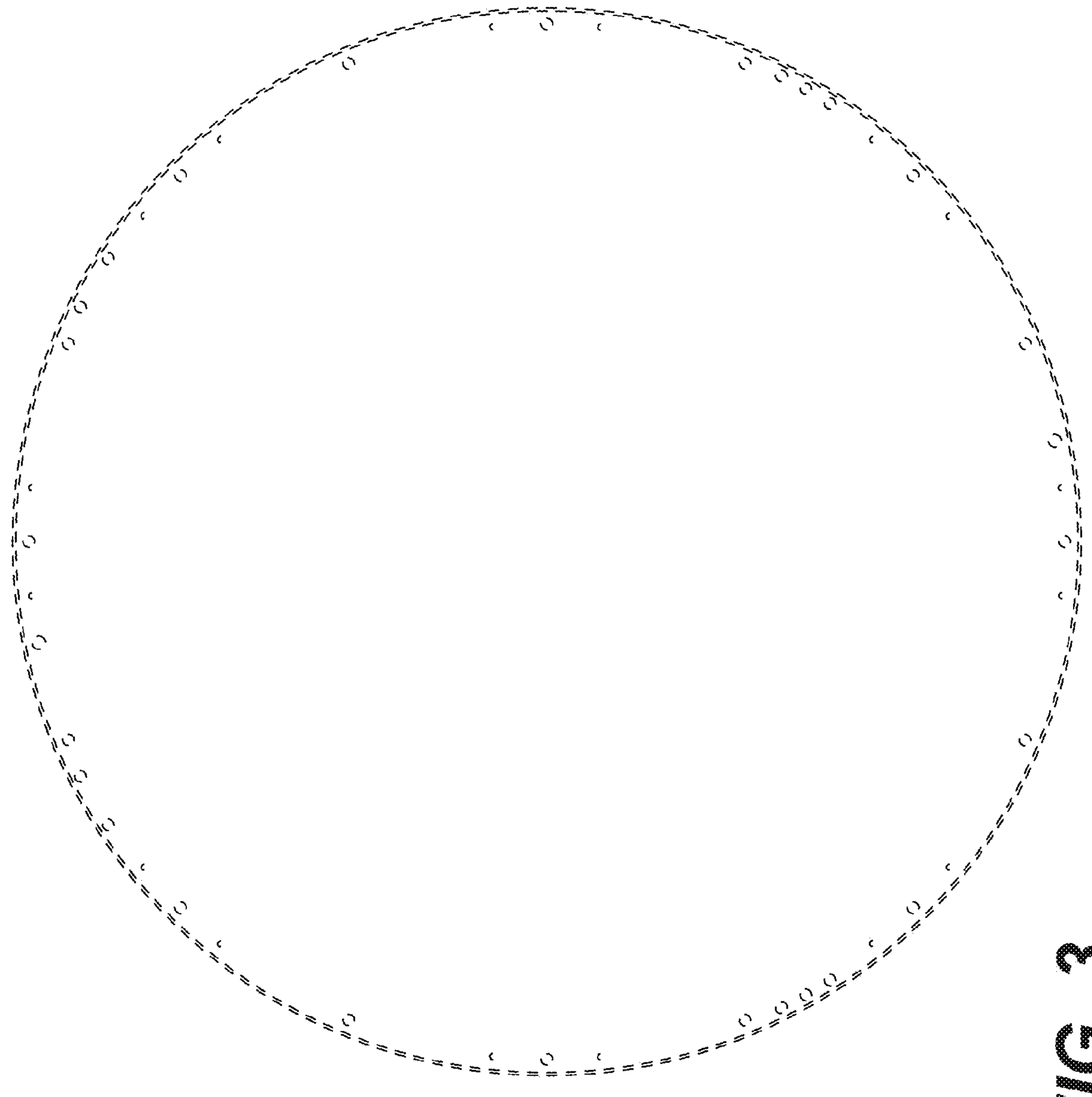

FIG. 3

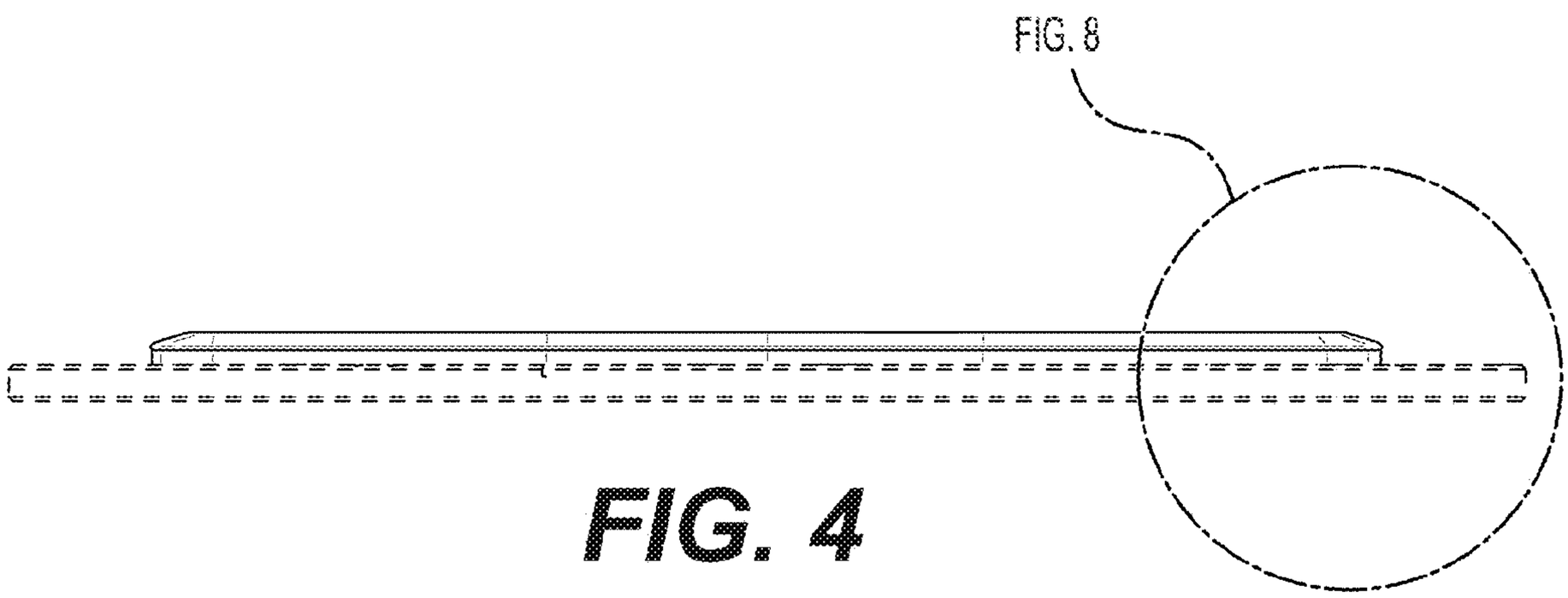

FIG. 4

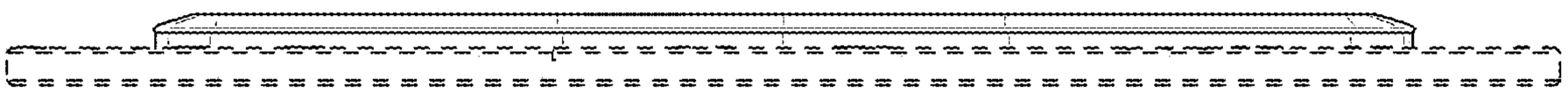

FIG. 5

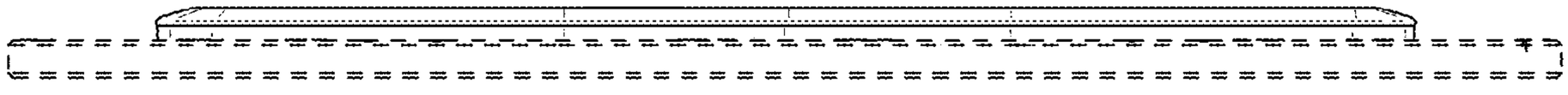

FIG. 6

FIG. 7

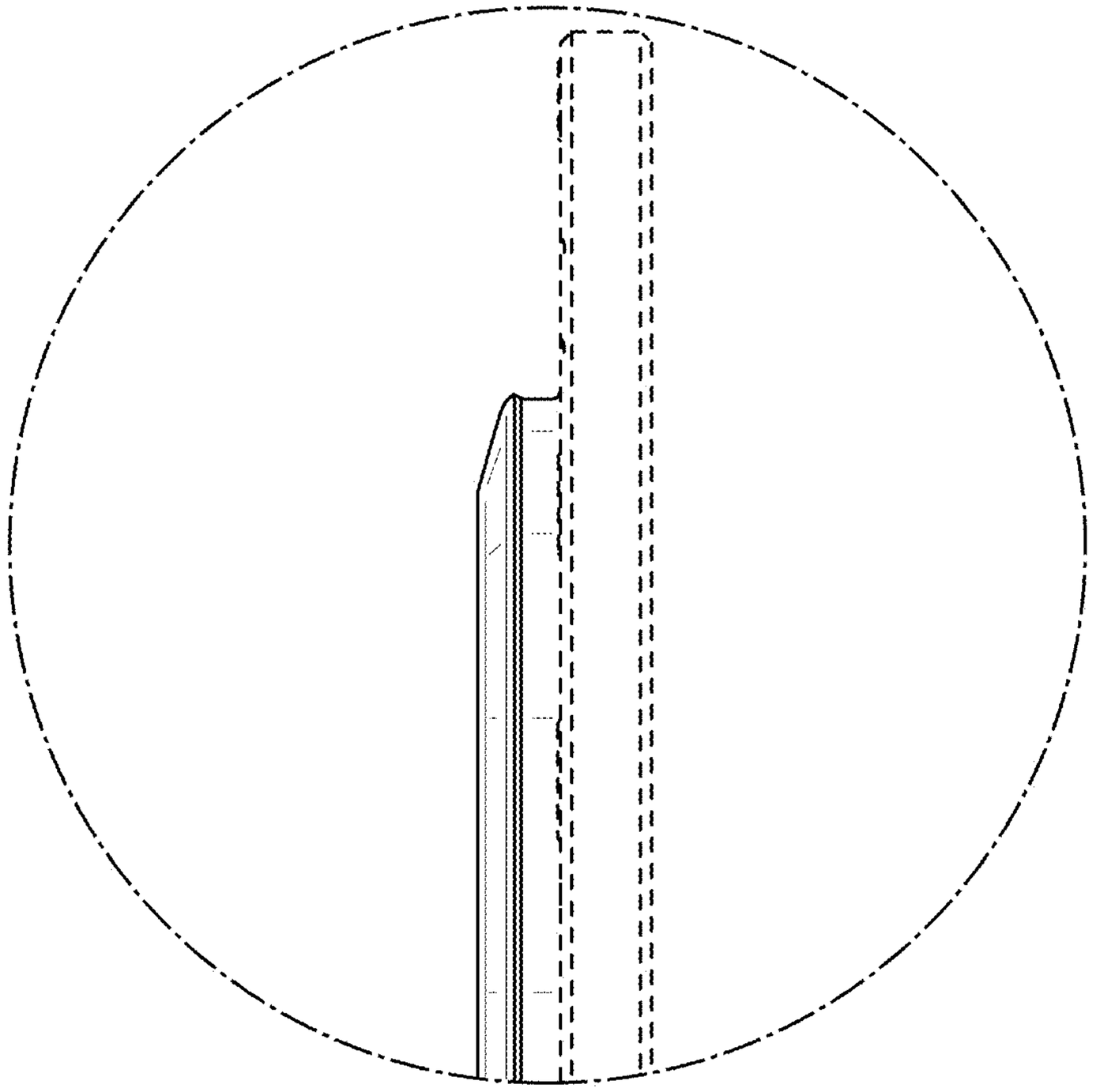

FIG. 8